

電気化学法よる $\text{Cu}_2\text{O}/\alpha\text{-Fe}_2\text{O}_3$ ヘテロ接合太陽電池の作製

Fabrication of Electrodeposited $\text{Cu}_2\text{O}/\alpha\text{-Fe}_2\text{O}_3$ Heterojunction Solar Cells

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Copper oxide (Cu_2O) and iron oxide ($\alpha\text{-Fe}_2\text{O}_3$) have attracted lots of interest for their semiconducting characteristics, and they have been studied for wide range of applications such as solar cells, photoanodes, etc. Additionally, Cu_2O can be deposited by employing electrodeposition technique which has been a new way for the fabrication of thin film semiconductors, and $\alpha\text{-Fe}_2\text{O}_3$ can be easily made by annealing of iron oxide hydroxides ($\gamma\text{-FeOOH}$). In this study, $\alpha\text{-Fe}_2\text{O}_3$ thin film is utilized as a potential n-type material to fabricate p-n heterojunction, and the photovoltaic properties of $\text{Cu}_2\text{O}/\alpha\text{-Fe}_2\text{O}_3$ heterojunction are evaluated and investigated. Recently successful fabrication of $\text{Cu}_2\text{O}/\text{FeOOH}$ p-n junction has been reported,¹⁾ but as far as we know, fabrication of $\text{Cu}_2\text{O}/\alpha\text{-Fe}_2\text{O}_3$ p-n junction has not yet been tried. Hence, this study has a possibility of offering new candidate materials in solar cell fabrications.

Prior to the fabrication of the $\text{Cu}_2\text{O}/\alpha\text{-Fe}_2\text{O}_3$ structure, the $\alpha\text{-Fe}_2\text{O}_3$ film was made by performing annealing on the $\gamma\text{-FeOOH}$ (as-depo) thin film at 400°C for 1 hour, and the $\gamma\text{-FeOOH}$ thin film was electrodeposited onto the ITO substrate at -0.9 (V vs SCE) from oxygen-bubbled 0.05 M FeSO_4 - 0.1 M Na_2SO_4 aqueous solution at room temperature and under stirred condition.²⁾ The $\alpha\text{-Fe}_2\text{O}_3$ film showed n-type conductivity with a band gap of $\sim 2.1\text{eV}$. The Cu_2O layer was then galvanostatically electrodeposited on the as-prepared $\alpha\text{-Fe}_2\text{O}_3$ thin film from 0.2 M CuSO_4 - 1.6 M lactic acid solution at $\text{pH} = 12.5$ (adjusted by KOH) and solution temperature of 40°C .

Figure 1 shows the Raman spectrum of the annealed sample with the measured typical Raman characteristics of commercial $\alpha\text{-Fe}_2\text{O}_3$ powder as standard. As shown in figure 2, the $\text{Cu}_2\text{O}/\alpha\text{-Fe}_2\text{O}_3$ and $\text{Cu}_2\text{O}/\gamma\text{-FeOOH}$ (as-depo) heterojunctions both exhibit rectifying properties and photovoltaic characteristics. The best values of the $\text{Cu}_2\text{O}/\alpha\text{-Fe}_2\text{O}_3$ heterojunction solar cell parameters are $V_{\text{OC}} = 0.038$ V and $J_{\text{SC}} = 1.12$ mA/cm^2 , which are not significantly different from those of the $\text{Cu}_2\text{O}/\gamma\text{-FeOOH}$ heterojunction. According to these results, there is no obvious difference between $\alpha\text{-Fe}_2\text{O}_3$ and $\gamma\text{-FeOOH}$ when they are applied as an n-type material to fabricate p-n heterojunction solar cells.

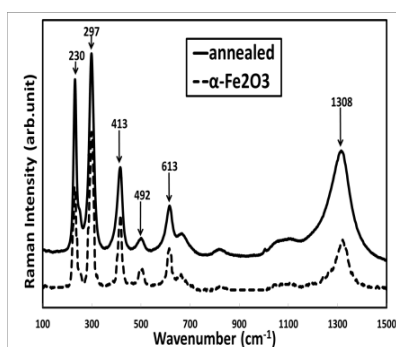


Figure.1 Raman spectra of the annealed sample and commercial $\alpha\text{-Fe}_2\text{O}_3$ powder.

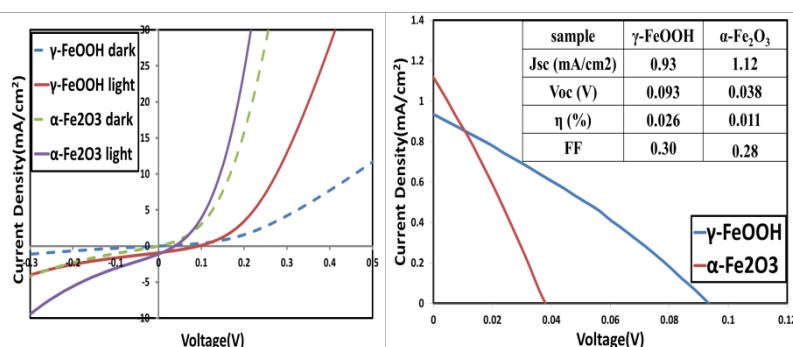


Figure.2 I-V characteristics and photovoltaic properties of the $\text{Cu}_2\text{O}/\alpha\text{-Fe}_2\text{O}_3$ (400°C) and $\text{Cu}_2\text{O}/\gamma\text{-FeOOH}$ (as-depo) heterojunctions.

References

- 1) J. J. M. Vequizo and M. Ichimura, Appl. Phys. Express 7, 045501 (2014).
- 2) J. J. M. Vequizo and M. Ichimura, Appl. Phys. Express 6, 125501 (2013).